

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicants:	Yeo, <i>et al.</i>	Docket No.:	TSM03-0926
Serial No.:	10/685,938	Art Unit:	2894
Filed:	October 15, 2003	Examiner:	Movva, Amar
For:	Dummy Pattern for Silicide Gate Electrode		

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**RESPONSE UNDER 37 CFR § 1.116**

Dear Sir:

Applicants respectfully submit the following remarks in response to Examiner's Office Action dated July 24, 2008, which Action is made final. Applicants respectfully request that these remarks be entered in pursuant to the provisions of 37 CFR § 1.116, and respectfully request reconsideration of the claims.